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- Proprietor: SUMITOMO ELECTRIC INDUSTRIES LIMITED No. 15, Kitahama 5-chome, Higashi-ku Osaka-shi, Osaka 541(JP)
- Sumitomo Electric Ind., Ltd. 1-1, Koyakita 1-chome ItamI-shi Hyogo(JP) Inventor: Tanaka, Saburo c/o Itami Works of Sumitomo Electric Ind., Ltd. 1-1, Kovakita 1-chome Itami-shi Hyogo(JP) Inventor: Fujita, Nobuhiko c/o Itami Works of Sumitomo Electric Ind., Ltd. 1-1, Koyakita 1-chome Itami-shl Hyogo(JP) Inventor: Yazu, Shuji c/o Itami Works of Sumitomo Electric Ind., Ltd. 1-1, Koyakita 1-chome ItamI-shi Hyogo(JP) Inventor: Jodal, Tetsuji c/o Itami Works of Sumitomo Electric Ind., Ltd. 1-1, Koyakita 1-chome itami-shi Hyogo(JP)

(7) Inventor: Itozaki, Hideo c/o Itami Works of

Representative: Mongrédien, André et al c/o SOCIETE DE PROTECTION DES INVEN-TIONS 25, rue de Ponthieu F-75008 Paris (FR)

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Description

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The present invention relates to a superconducting thin film and a method for preparing the same. More particularly, it relates to a superconducting thin film composed of compound oxide having a high critical temperature and also possessing lasting stability for a long period and a method for preparing the same.

The superconductivity is a phenomenon which is explained to be a phenomenon of a kind of phase change of electrons under which the electrical resistance become zero and the perfect diamagnetism is observed. Thus, under the superconducting condition, electric current of a very high current density can be delivered without any loss of power.

Therefore, if the superconducting power cable is realized, the power loss of about 7 % which is inevitable in the conventional power cables can be reduced sharply. Realization of superconducting coils which can generate a very high magnetic field is expected to accelerate development in the field of fusion power generation in which the electric power is consumed beyond its output under the present technology, as well as in the field of MHD power generation or motor-generators. The development of superconductivity are demanded also in the other industrial fields such as in the field of electric power reservation; in the field of transportation, for example magnetic levitation trains or magnetically propelling ships; in the medical field such as high-energy beam radiation unit; or in the field of science such as NMR or high-energy physics.

In addition to the abovementioned electric power applications, the superconducting materials can be used in the field of electronics, for example, as a device using the Josephson effect in which quantum efficiency is observed macroscopically when an electric current is passed through a weak junction arranged between two superconductors. Tunnel junction type Josephson device which is a typical application of the Josephson effect is expected to be a high-speed and low-power consuming switching device owing to smaller energy gap of the superconducting material. It is also expected to utilize the Josephson device as high sensitive sensors or detectors for sensing very weak magnetic field, microwave, radiant ray, or the like since variation of electromagnetic wave or magnetic field is reflected in variation of Josephson effect and can be observed as a quantum phenomenon precisely. Development of the superconducting devices is also demanded in the field of high-speed computers in which the power consumption per unit area is reaching to the upper limit of the cooling capacity with increment of the integration density in order to reduce energy consumption.

However, the critical temperature could not exceed 23.2 K of Nb₃Ge which was the the highest Tc for all studies for the past ten years.

The possibility of an existence of new types of superconducting materials having much higher Tc was revealed by Bednorz and Müller, who discovered a new oxide type superconductor in 1986 [Z. Phys. B64 (1986) 189]

It had been known that certain ceramics material of compound oxides exhibit the property of superconductivity. For example, U. S. patent No. 3,932,315 discloses Ba-Pb-Bi type compound oxide which shows superconductivity and Japanese patent laid-open No. 60-173,885 discloses another type superconductor composed of Ba-Bi type compound oxide. These superconductors, however, possess rather lower transition temperatures of about 10 K, and hence usage of liquidized helium (boiling point of 4.2 K) as cryogen is indispensable to realize superconductivity.

The new type compound oxide superconductor discovered by Bednorz and Müller is represented by [La, Sr]₂CuO₄ which is called the K₂NiF₄-type oxide having a crystal structure which is similar to known perovskite type oxides. The K₂NiF₄-type oxides show such higher Tc as 30 K which are extremely higher than known superconducting materials.

It was also reported in that C. W. Chu et al. discovered, in the United States of America, another superconducting material so called YBCO type represented by YBa₂Cu₃O_{7-x} having a critical temperature of about 90 K in February 1987.

And hence, the possibility of an existence of high-temperature superconductors have burst onto the scene.

The new type superconductor of compound oxide, however, is not stable and hence their superconductivity is lost or deteriorates with the passing of time. In fact, there is such a tendency that their critical temperature and critical current density drop gradually with the passing of time. This tendency is noticeable in the case of a thin film prepared by a physical vapour deposition technique. This fact is explained by defectiveness of oxygen deficiency, in other words, imperfect oxygen contents in the crystal. It is known that the superconducting property of compound oxide is influenced by the oxygen contents or oxygen deficiency in their crystalline structures. In order to overcome such drawback, the deposited thin film prepared by the physical vapour deposition technique is usually heat-treated or annealed, particularly in the final stage of preparation, in the presence of oxygen gas. In fact, if the deposited thin film is not heat-

treated, its superconducting property is very poor.

However, even if the deposited thin film is heat-treated, it is impossible to prevent the thin film from deterioration of superconducting property which occur with the passing of time. Such deterioration may be caused by the abovementioned defectiveness of oxygen deficiency which is resulted from that the compound oxide react with water in air and that oxygen in the crystal escape with the passing of time, so that a quasi-stable phase of the superconducting compound oxide is transformed to a non-superconducting phase. The deterioration of superconductivity, in other words such a tendency that the superconducting property is lost gradually in time is a big problem of compound oxide type superconductors in their actual uses.

Therefore, an object of the present invention is to overcome the abovementioned problems of the conventional technique and to provide a superconducting thin film improved in stability during storage or during actual use and a method for preparing the same.

Summary of the Invention

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According to the present invention, an outer surface of a superconducting thin film composed of compound oxide and deposited on a substrate is covered with a protective layer which is composed of polymer compound.

The polymer compound is selected from a group comprising silicon resins, and epoxy resin which are used as a passivation layer in the field of LSI.

These polymer compounds can produce a high density protective film layer, so that they can suppress liberation of oxygen from the crystalline superconducting thin film, and hence they can advantageously maintain the superconducting property of the thin film for a long time. Still more, they do not exert any undesired influence upon the superconducting thin film, since they are chemically stable and can be prepared on the superconducting thin film layer at a low temperature such as room temperature.

The protective film layer of polymer compound can be prepared by the conventional coating techniques such as spin coating, dipping, spraying or the like with solvent. The protective film layer of polymer compound can be prepared directly by applying molten polymer without solvent onto a surface of the superconducting thin film. In a special case, the protective layer of polymer can be formed directly in a transfer molding machine.

During formation of the protective layer of polymer compound, the substrate should be maintained at a temperature which is lower than 500 °C. In fact, if the thin film deposited is heated at a temperature which is higher than 500 °C, oxygen in the crystal of the superconducting thin film is apt to be lost to deteriorate the superconductivity. Therefore, the temperature of the substrate during and/after the formation of the protective layer should be kept lower than 500 °C. Usually, the substrate is not heated higher than a curing temperature of the polymer after the protective layer is deposited.

According to the present invention, more than two protective layers may be formed successively on the superconducting thin film layer. Each protective layer may be different in type and in composition from adjacent layers.

The superconducting thin film is composed of compound oxide of an element α selected from IIa group of the Periodic Table, an element β selected from IIIa group of the Periodic Table, copper and oxygen.

Particularly, the superconducting thin film is preferably a compound oxide represented by the general formula:

5 (α_{1-x}β_x)Cu_yO_z

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in which α and β means the same definition as above, x is an atomic ratio of β with respect to $(\alpha + \beta)$ and has a range of $0.1 \le x \le 0.9$, and y and z are respective atomic ratios with respect to $(\alpha_{1-x}\beta_x)$ which is considered to be equal to 1 and each satisfies respective range of $0.4 \le y \le 3.0$ and $1 \le z \le 5$.

According to a preferred embodiment of the present invention, the element α is Ba or Sr and the element β is at least one element selected from a group comprising Y, La, Gd, Dy, Ho, Er, Tm, Yb, Nd, Sm, Eu and Lu. From 10 to 80 % of the element α may be substituted by one or more than one of other elements selected from Ila group of the Periodic Table. The element β may be a combination of more than two other elements selected from Illa group of the Periodic. A portion of these components may be substituted, if necessary, by at least one of elements selected from a group comprising Al, Fe, Co, Ni, Zn, Ag and Ti.

An atomic ratio of α to β depends on type or system of the compound oxide or on the combination of α and β . For example, following atomic ratios are preferably used in case of Ba-Y system and Ba-La system:

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Y/(Y + Ba)	0.06 to 0.94, more preferably 0.1 to 0.4
Ba/(La + Ba)	0.04 to 0.96, more preferably 0.08 to 0.45

Thus, the preferable compound oxides are Y-Ba-Cu-O system, La-Ba-Cu-O system and La-Sr-Cu-O system including the following special cases:

Y ₁ Ba ₂ Cu ₃ O _{7-x} , Sm ₁ Ba ₂ Cu ₃ O _{7-x} , Eu ₁ Ba ₂ Cu ₃ O _{7-x} , Tm ₁ Ba ₂ Cu ₃ O _{7-x} , (La, Sr) ₂ CuO _{4-x}	Ho ₁ Ba ₂ Cu ₃ O _{7-x} , Nd ₁ Ba ₂ Cu ₃ O _{7-x} , Er ₁ Ba ₂ Cu ₃ O _{7-x} , Yb ₁ Ba ₂ Cu ₃ O _{7-x} ,	Lu ₁ Ba ₂ Cu ₃ O _{7-x} , Gd ₁ Ba ₂ Cu ₃ O _{7-x} , Dy ₁ Ba ₂ Cu ₃ O _{7-x} , La ₁ Ba ₂ Cu ₃ O _{7-x} ,
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5 in which x is a number which satisfies a range of 0 < x < 1.

The above-mentioned compound oxides possess preferably perovskite type or quasi-perovskite type crystal structure. The term quasi-perovskite type means a structure which can be considered to have such a crystal structure that is similar to perovskite-type oxides and includes an orthorhombically distorted perovskite or a distorted oxygen-deficient perovskite or the like.

The substrate may be made of glass, quartz, silicon, sapphire, stainless steel or other ceramics. Particularly, the substrate consists preferably of a single crystal of MgO or SrTiO₃. Desirably, the superconducting thin film is deposited on a {001} plane or {110} plane of a single crystal of MgO or SrTiO₃ to improve the critical current density (Jc) owing to ordering of Crystal to c-axis.

The thin film of superconductor can be prepared by the conventional physical vapour deposition technique such as sputtering, vacuum deposition, ion plating, molecular beam epitaxial growth or the like. It is also possible to use a chemical deposition technique (CVD) such as plasma CVD or photo CVD.

In operation, the thin film of compound oxide is prepared by sputtering technique and then a protective layer is applied on a surface of the superconducting thin film deposited. Such superconducting thin film can be prepared by sputtering technique described in our co-pending United States of America patent serial No. 152,714 filed on May 2, 1988.

In the case of PVD, a vapour source may be elements of α , β and γ themselves, oxides or carbonates thereof. An atomic ratio of these elements in the vapour source is adjusted in function of evaporation rates of these elements on the basis of an atom ratio of these elements in the thin film to be produced. For example, the atomic ratio of the elements α , β and copper in the vapor source is preferably selected from following range for typical compound oxide systems:

Y/(Y + Ba)	0.06 to 0.94, more preferably 0.1 to 0.4
Ba/(La + Ba)	0.04 to 0.96, more preferably 0.08 to 0.45

The vapour source may be a sintered mass or a powder which is prepared by pulverizing the sintered mass which is prepared, for example by sintering a powder mixture of Y_2O_3 , CuO and BaCuO₂ and which may have a crystal structure of perovskite or quasi-perovskite type. The sintering operation can be carried out, for example at a temperature selected in the following range:

Y/(Y + Ba)	220 to 1,230 °C
, ,	234 to 1,260 °C
Ba/(La + Ba)	234 10 1,200 0

The vapour source may be divided into more than two segments, for example two segments consisting of a copper target and a target composed of Ba-Y compound oxide or three targets consisting of CuO, Y₂O₃ and BaO.

The superconducting property can be improved by heat-treatment which is effected in oxygen containing atmosphere after the thin film of compound oxide is deposited on the substrate. The heat-treatment is preferably effected under a partial pressure of oxygen ranging from 0.1 to 150 atm at a temperature between 300 and 1,500 °C. After this temperature is maintained for more than one hour, the resulting thin film is cooled slowly at a rate of less than 100 °C/min, preferably at a rate of less than 10 °C/min. Advantage of the heat-treatment can not be obtained if the heat-treatment is effected outside the

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abovementioned conditions. For example, if the thin film is heated at a temperature which is higher than 1,500 °C, the abovementioned advantage can not be obtained but the superconductivity will disappear. In the case of compound oxide type superconductor, oxygen deficiency in its crystal is a critical factor for realizing the superconductivity, so that the heat-treatment under a relatively higher partial pressure of oxygen is very preferable and is considered to be indispensable for realizing superior superconductivity.

However, it is impossible to prevent the thin film of compound oxide from deterioration which occur during storage even if the thin film is heat-treated completely. The deterioration of superconductivity, in other words a phenomenon that the superconducting property is lost gradually in time may be caused by disappearance or liberation of oxygen out of the crystal because the superconductivity of compound oxide is not a stable condition but is observed in a quasi-stable phase. This is a big problem of compound oxide type superconductors in their actual use.

This problem is solved by the present invention in which an outer surface of the thin film of superconductor is covered by a protective layer of chemically stable polymer compound which can be applied at a relatively low temperature and which has a high density to prevent oxygen from escaping from its crystal structure.

It is apparent from the description abovementioned that the superconducting thin film of compound oxide according to the present invention has improved stability than conventional superconducting thin films, and hence it can be utilized advantageously in applications of thin film devices such as Matisoo switching element, Josephson device, Anacker memory device and Superconducting Quantum Interference Device (SQUID).

Now, several embodiments of the method according to the present invention will be described by Examples, but the scope of the present invention should not be limited thereto.

In the following Examples, two series of samples are prepared in such manner that the first series possess the protective layer of polymer according to the present invention, while second series do not possess the same.

The following examples 1 and 2 are for technical information only and are not within the scope of the claims.

Example 1

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Powders of Y_2O_3 and BaCO₃ are mixed in an atomic ratio of Y: Ba = 1:2. Then, a powder of CuO is added to the resulting powder mixture in a proportion which is 10 % excess with respect to an atomic ratio of Y: Ba: Cu = 1:2:3. The resulting powder mixture is sintered at 950 °C to obtain a sintered block of YBa₂Cu₃O₇ which will be used as a target for depositing a superconducting thin film.

The resulting target is set on a target holder and a substrate (100 mm ϕ) consisting of a single crystal of MgO is secured on a substrate holder in such a manner that its surface on which the thin film is deposited has a {001} plane.

After a chamber 1 is vacuumed, argon gas at a partial pressure of 5.0×10^{-2} Torr and oxygen gas at a partial pressure of 1.0×10^{-2} Torr are introduced and the substrate is heated at 670 °C. Then, a magnetron electrode is energized with a high frequency of 3 W/cm² to prepare a thin film of compound oxide of 1 μ m on the substrate at a film-forming rate of 0.50 Å/sec.

After deposition of the thin film of compound oxide complete, the deposited thin film is left in an atmosphere of oxygen at a partial pressure of 1 atom for 15 hour with heating the substrate at 650 °C and then cooled slowly at a cooling rate of 7 °C/min.

After the heat-treatment, a surface of the thin film is coated with polyimide (Dupont) by spin-coating technique and cured at 300 °C for 30 minute to form a polyimide protective layer of 5 µm.

Resistance of the resulting thin film is measured on a sample on which aluminum electrodes are vacuum-deposited at opposite ends of the thin film of compound oxide deposited on the substrate.

Measurement of the critical temperature Tc and Tcf is carried out by the conventional four probe method in which the sample is immersed in liquidized helium to cool the sample down to a temperature of 8 K in a cryostat. Then, the temperature dependence of resistance of the sample is measured with rising the temperature gradually to determine a temperature of Tcf at which the perfect superconductivity start to be lost and a resistance begin to appear and a temperature of Tc at which the superconductivity is lost and an ordinary resistance begin to appear.

Changes of Tcf and Tc are determined by comparing two values observed on same sample just after the protective layer is deposited and after one month.

The result as well as main operational parameters are shown in Table 1.

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Example 2

The same procedure as Example 1 is repeated except that a sintered block of $LaBa_2Cu_3O_7$ is used as a target for depositing a thin film of compound oxide on the substrate. The target is prepared by the following procedure:

Powders of La_2O_3 and $BaCO_3$ are mixed in an atomic ratio of La:Ba=1:2 and then a powder of CuO is added to the resulting powder mixture in 10 % excess of an atomic ratio of La:Ba:Cu=1:2:3. Then, the resulting powder mixture is sintered at 970 °C to obtain a sintered block of $LaBa_2Cu_3O_7$ which is used as a target for a superconducting thin film.

The result as well as main operational parameters are shown in Table 1.

Table 1

15	No.	Partial pressure of O ₂ (Torr)	Temperature of Substrate (• C)	Protective Layer	Just after deposition		One month later	
					Tc (K)	Tcf (K)	Tc (K)	Tcf (K)
	1	1.0×10 ⁻²	670	polyimide	85	69	86	68
20				•	83	68	22	
	2	7.0×10 ⁻³	650	polyimide	58	39	57	38
				-	58	39		
25	(Note	e) : Superconduc	ctivity is not observ	ved in liquid helium		•		

Example 3

The same procedure as Example 1 is repeated except that the polyimide is replaced by epoxy resin (Shinetsu Kagaku) to form a protective layer of epoxy resin of about 1 mm.

The result as well as main operational parameters are shown in Table 2.

Example 4

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The same procedure as Example 2 is repeated except that the polyimide is replaced by epoxy resin (Shinetsu Kagaku) to form a protective layer of epoxy resin of about 1 mm.

The result as well as main operational parameters are shown in Table 2.

Table 2

No.	Partial pressure of O₂ (Torr)	Temperature of Substrate (*C)	Protective Layer	Just after deposition		One month later	
				Tc (K)	Tcf (K)	Tc (K)	Tcf (K)
3	8.0×10 ⁻³	720	ероху	89	77	97	78
			÷	90	75	21	-
4	4 5.0×10 ⁻³	630	ероху	48	31	42	33
			•	42	31	-	-

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Claims

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 A superconducting thin film of compound oxide deposited on a substrate and represented by the formula (1):

 $(\alpha_{1-x}\beta_x)Cu_yO_z$ (1)

in which α is a lla group element, β is a llla group element, x is an atomic ratio of β with respect to $(\alpha + \beta)$ and has a range of $0.1 \le x \le 0.9$, and y and z are respective atomic ratios with respect to $(\alpha_{1-x}\beta_{x})$ which is considered to be equal to 1 and each satisfy ranges of $0.4 \le y \le 3.0$ and $1 \le z \le 5$ respectively, characterized in that an outer surface of said superconducting thin film is covered with a protective layer made of organic polymer of silicon resin or epoxy resin.

- The superconducting thin film set forth in claim 1 wherein said element α is Ba and said element β is an element selected from a group comprising Y, La, Gd, Dy, Ho, Er, Tm, Yb, Nd, Sm, Eu and Lu.
 - 3. The superconducting thin film set forth in claim 1 wherein said compound oxide contains Sr, La, Cu and at least one element selected from a group comprising Al, Fe, Co, Ni, Zn, Ag and Ti.
- 20 4. The superconducting thin film set forth in any one of claim 1 to 3 wherein said superconducting thin film has a crystal structure of perovskite or quasi-perovskite.
 - 5. The superconducting thin film set forth in any one of claim 1 to 4 wherein said substrate is made of glass, quartz, silicon, sapphire, stainless steel or other ceramics.
 - 6. The superconducting thin film set forth in claim 5 wherein said substrate is a single crystal of MgO or SrTiO₃.
- 7. The superconducting thin film set forth in claim 6 wherein said superconducting thin film is deposited on a {001} plane or {110} plane of a single crystal of MgO or SrTiO₃.

Patentansprüche

 Supraleitender Dünnfilm eines Mischoxids, das auf einem Substrat aufgebracht ist und durch die folgende Formel (1) wiedergegeben wird:

$$(\alpha_{1-x}\beta_x)Cu_yO_z$$
 (1)

- worin α ein Element der Gruppe Ila ist, β ein Element der Gruppe Illa ist, x ein Atomverhältnis von β in Bezug auf $(\alpha + \beta)$ ist und einen Bereich von $0,1 \le x \le 0,9$ besitzt und y und z jeweils Atomverhältnisse in Bezug auf $(\alpha_{1-x}\beta_x)$ sind, von dem angenommen wird, das es 1 entspricht, und die jeweils Bereichen von $0,4 \le y \le 3,0$ bzw. $1 \le z \le 5$ entsprechen, dadurch gekennzeichnet, daß eine Außenfläche des supraleitenden Dünnfilms eine Schutzschicht aus einem organischen Polymeren aus einem Silikonharz oder einem Epoxyharz trägt.
 - 2. Supraleitender Dünnfilm nach Anspruch 1, worin das Element α Ba ist und das Element β ein Element aus der Gruppe ist, die Y, La, Gd, Dy, Ho, Er, Tm, Yb, Nd, Sm, Eu und Lu umfaßt.
- Supraleitender Dünnfilm nach Anspruch 1, worin das Mischoxid Sr, La, Cu und mindestens ein Element
 aus der Gruppe enthält, die Al, Fe, Co, Ni, Zn, Ag und Ti umfaßt.
 - Supraleitender Dünnfilm nach einem der Ansprüche 1 bis 3, worin der supraleitende Dünnfilm eine Perovskit- oder Quasi-Perovskit-Kristallstruktur besitzt.
- 55 5. Supraleitender Dünnfilm nach einem der Ansprüche 1 bis 4, worin das Substrat aus Glas, Quarz, Siliziumdioxid, Saphir, rostfreiem Stahl oder anderen keramischen Materialien hergestellt ist.
 - 6. Supraleitender Dünnfilm nach Anspruch 5, worin das Substrat ein Einkristall von Mgo oder SrTiO3 ist.

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7. Supraleitender Dünnfilm nach Anspruch 6, worin der supraleitende Dünnfilm auf einer geschwungenen (001 geschwungenen)-Ebene oder einer {001}- oder {110}-Ebene eines Einkristalls von MgO oder SrTiO3 abgeschieden ist.

5 Revendications

- 1. Film mince supraconducteur d'oxyde complexe déposé sur un substrat et représenté par la formule (1)
- 10 $(\alpha_{1-x}B_x)Cu_yO_z$ (1)

dans laquelle α est un élément du groupe lla, β est un élément du groupe llla, x est un rapport atomique de β par rapport à $(\alpha + \beta)$ et est compris dans l'intervalle $0,1 \le x \le 0,9$, et y et z sont les rapports atomiques respectifs par rapport à $(\alpha_{1-x}\beta_{x})$ qui est considéré comme étant égal à 1 et chacun satisfait aux intervalles $0,4 \le y \le 3,0$ et $1 \le z \le 5$, respectivement, caractérisé en ce que la surface externe dudit film mince supraconducteur est recouverte d'une couche protectrice faite d'un polymère organique de résine de silicone ou de résine époxyde.

- Film mince supraconducteur selon la revendication 1, dans lequel ledit élément α est Ba et ledit élément β est un élément choisi dans le groupe constitué par Y, La, Gd, Dy, Ho, Er, Tm, Yb, Nd, Sm, Fu et Lu
 - 3. Film mince supraconducteur selon la revendication 1, dans lequel ledit oxyde complexe contient Sr, La, Cu et au moins un élément choisi dans le groupe constitué par Al, Fe, Co, Ni, Zn, Ag, et Ti.
 - 4. Film mince supraconducteur selon l'une quelconque des revendications 1 à 3, dans lequel ledit film mince supraconducteur a une structure cristalline de perovskite ou de quasi-perovskite.
- 5. Film mince supraconducteur selon l'une quelconque des revendications 1 à 4, dans lequel ledit substrat est fait de verre, de quartz, de silicium, de saphir, d'acier inoxydable ou d'autres céramiques.
 - 6. Film mince supraconducteur selon la revendication 5, dans lequel ledit substrat est un monocristal de MgO ou SrTiO₃.
- 7. Film mince supraconducteur selon la revendication 6, dans lequel ledit film mince supraconducteur est déposé sur le plan {001} ou {110} d'un monocristal de MgO ou SrTiO₃.

ΔO

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